

Diffusion of Chromium in Thin Hydrogenated Amorphous Silicon Films

Pershelyev SK, Drapacz PR, Rose MJ, Fitzgerald AG.

Semiconductors

2004; 38(3):344-346

ARTICLE IDENTIFIERS

DOI: 10.1134/1.1682341

PMID: unavailable

PMCID: not available

JOURNAL IDENTIFIERS

LCCN: not available

pISSN: 1063-7826

eISSN: not available

OCLC ID: not available

CONS ID: not available

US National Library of Medicine ID: not available

This article was identified from a query of the SafetyLit database.